

RECEIVED PATENT APPLICATION

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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

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In re the Application of

Yasukazu HAYASHI

Group Art Unit: 2834

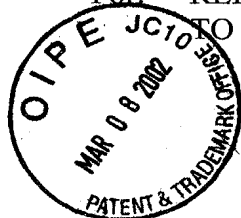
Application No.: 09/887,015

Examiner: G. Perez

Filed: June 25, 2001

Docket No.: 109920

For: RELUCTANCE TYPE RESOLVER WITH REDUCED DETECTION ERROR DUE
TO EXTERNAL MAGNETIC FLUX



REQUEST FOR APPROVAL OF DRAWING CORRECTIONS

Director of the U.S. Patent and Trademark Office
Washington, D.C. 20231

Sir:

The Examiner is requested to review and approve the proposed corrections to
Figures 3-5, marked in red on the attached copy of such drawing figures.

Upon approval by the Examiner, and upon allowance of this application, the formal
drawings will be corrected.

Respectfully submitted,

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JAO:MMI/sxb

Date: March 8, 2002

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